



PATENT
Customer No. 22,852
Attorney Docket No. 04329.2553

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of:)
Masaki HATANO, et al.) Group Art Unit: 2822
Serial No.: 09/816,177) Examiner: Mitchell, James M.
Filed: March 26, 2001)
For: SEMICONDUCTOR DEVICE)

Assistant Commissioner for Patents
Washington, DC 20231

Sir:

AMENDMENT

In reply to the Office Action dated December 26, 2001, with a period for response extending through April 26, 2002, by the attached Petition for Extension of Time of One Month and requisite fee payment, please amend the application as follows:

IN THE CLAIMS:

Please cancel claims 3 – 12 without prejudice or disclaimer of the subject matter therein, amend claim 1, and add new claims 13 – 22 as follows:

1. (Amended) A semiconductor device comprising:
a Cu film provided above a main surface of a semiconductor substrate and used as a wiring;
an intermediate layer formed at least on the Cu film, the intermediate layer comprising a TaN film formed on the Cu film and a Ta film formed on the TaN film; and
an Al film formed on the Ta film and used as a pad.

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